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Highly efficient deprotection of phenolic tetrahydropyranyl and methoxymethyl ethers and sequel cyclization to indanones using Sn(IV)Cl₄ catalyst

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| 1 | Highly efficient deprotection of phenolic tetrahydropyranyl and methoxymethyl ethers and |
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| 2 | sequel cyclization to indanones using Sn(IV)Cl ₄ catalyst |
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| 7 | Abstract: |
| 8 | Sn(IV)Cl ₄ catalyst provided a rapid and efficient deprotection method for the phenolic THP and |
| 9 | MOM ethers and sequel intramolecular Friedel-Crafts alkylation reaction of THP and MOM |
| 10 | protected chalcone epoxides under mild conditions. The reaction took 2-3 min to give the |
| 11 | products in excellent yield (90-98%) at 0 $^{\circ}$ C without affecting the other functional groups. |
| 12 | Keywords: Alcohol, Phenol, SnCl ₄ , detetrahydropyranylation, demethoxymethylation, Friedel- |
| 13 | Crafts alkylation. |
| 14 | Protection-deprotection of the functional groups is the most frequent used strategies in |
| 15 | the multi-steps organic syntheses. In particular, the protection and the deprotection of hydroxyl |
| 16 | group is extremely important because of its enormous demand for the synthesis of a number of |
| 17 | compounds of biological and synthetic interest such as carbohydrates, macrolides, peptides, |
| 18 | steroids, nucleotides and polyethers. ¹ The protection of hydroxyl groups with 3,4-dihydro-2H- |
| 19 | pyran is the most frequent used method due to stability of the resulting 2-tetrahydropyranyl |
| 20 | ethers (THPEs) in the presence of strong bases or nucleophiles such as Grignard reagents, |
| 21 | organolithium compounds, metal hydrides, catalytic hydrogenation, alkylating and acylating |

agents.² Similarly, methoxymethyl chloride (MOMCl) is an another important reagent for the
 hydroxyl group protection.³

The deprotection of THP and MOM ethers therefore required efficient methods to avoid 24 the decomposition of the products and/or loss of other functional groups in the products under 25 harsh reaction conditions. Therefore, several catalysts have been explored for the 26 detetrahydropyranylation of alcohols and phenols that include protic acids,⁴ Lewis acids like 27 BF₃-etherate,⁵ LiBr,⁶ LiBF₄,⁷ LiOTf,⁸ LiClO₄⁹ Sc(OTf)₃,¹⁰ In(OTf)₃,¹¹ I₂,¹² InCl₃,¹³ ZrCl₄,¹⁴ 28 CuCl₂,¹⁵ and NH₄Cl,¹⁶ expansive graphite,¹⁷ clay materials,¹⁸ silica-supported sulfuric acid,¹⁹ and 29 other miscellaneous catalysts.²⁰⁻²⁵ Similarly, many catalysts have been used for the 30 demethoxymethylation of alcohols and phenols such as HCl, BBr₃, pyridinium *p*-toluene 31 sulphonate under strong acidic condition, mild Lewis acids ZnBr₂, and TiCl₄ in aprotic 32 conditions and BBr₃ derivatives Me₂BBr, and (i-PrS)₂BBr.²⁶ Most of these methods have 33 different drawbacks such as longer reaction time, low yields, refluxing at high temperature and 34 the tedious work-up procedures. Hence, there is still a scope to develop mild and efficient 35 methods in the deprotection of tetrahydropyranyl and methoxymethyl ethers. 36

In continuation of our interest to develop new methods for the synthesis and the acid catalysis reactions,²⁷ herein, we report an efficient deprotection method of the THP and the MOM ethers and sequel Friedel-Crafts alkylation reaction of the protected THP and MOM chalcone epoxides using SnCl₄ catalyst under mild reaction conditions.

The catalytic efficiency of different metal halides was screened (Table 1). The metal halides (Table 1, entries 1-5) showed poor to moderate catalytic activity. InCl₃ (Table 1, entry 6) was found to be a better catalyst at 10 mol% catalyst loading, which gave 90% yield of the cyclized products without deprotecting the THP or the MOM ethers. However, the reaction was

| 45 | completed in 4-5 hours. SnCl ₄ (Table 1, entries 7, 8) at less than 10 mol% catalyst loading gave |
|--|---|
| 46 | lower yields in a longer reaction time. SnCl ₄ (Table 1, entry 9) at 10 mol% catalyst loading was |
| 47 | found to be the most efficient catalyst, which gave the optimal yield (98%) with deprotecting the |
| 48 | THP and the MOM ethers within 2-3 min. Further, increase in the catalyst loading of SnCl4 |
| 49 | (Table 1, entry 10) gave the side-product as 3-(4-chlorophenyl)-2-chloro-2,3-dihydro indan-1- |
| 50 | one along with the desider product. We also applied SnI_4 and $SnBr_4$ in 5, 10, and 20 mol% |
| 51 | catalysts loading during the deprotection of THP and MOM ethers. However, it gave the desired |
| 52 | products only 5-10% yields after stirring for 2-6 h at 0 °C. |
| 53 | [Table 1] |
| 54 | We observed the solvent effects using different solvents like CH ₃ COCH ₃ , CHCl ₃ , CH ₂ Cl ₂ |
| 55 | and THF. CHCl ₃ and CH ₂ Cl ₂ were found to be the desired solvents (Table 2, entries 4, 6). |
| 56 | |
| 50 | [Table 2] |
| 57 | Under optimized reaction conditions, the deprotection of THP and MOM ethers in |
| 57 58 | Under optimized reaction conditions, the deprotection of THP and MOM ethers in phenols, chalcone and chalcone epoxides were achieved using 10 mol% of SnCl ₄ in excellent |
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| 57 58 59 60 | Tradie 2 Under optimized reaction conditions, the deprotection of THP and MOM ethers in phenols, chalcone and chalcone epoxides were achieved using 10 mol% of SnCl ₄ in excellent yields (90-98%) within 2-3 min at 0 $^{\circ}$ C in the presence of other functional groups. However, in the case of alcoholic THP and MOM ethers, even 20 mol% of catalyst loading gave less yield 10 |
| 50 57 58 59 60 61 | Under optimized reaction conditions, the deprotection of THP and MOM ethers in phenols, chalcone and chalcone epoxides were achieved using 10 mol% of SnCl ₄ in excellent yields (90-98%) within 2-3 min at 0 ^o C in the presence of other functional groups. However, in the case of alcoholic THP and MOM ethers, even 20 mol% of catalyst loading gave less yield 10 and 25% respectively (Table 3, entry 1). In case of chalcones 6-13 , only THP or MOM removal |
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[Table 3]

The stereochemistry and the diastereomeric excess ratio of the indanone derivatives 14-19 were 68 determined by the chiral column separation of racemic mixture of diastereomers. For example, in 69 the synthesis of racemic indanone 3-(4-bromophenyl)-2-hydroxy-2, 3-dihydroindan-1-one 70 71 (Scheme 1), the chiral HPLC purification gave peaks at 40.14 (51%) and 56.43 (49%) min. for the diastereomers (See Supporting Information). Then, we synthesized enantiomerically excess 72 (ee) *trans*-chalcone epoxide of 2R, 3S-configuration from chalcone with α, α' -diphenyl-L-prolinol 73 and TBHP in hexane which gave a good yield (58%) with 77.6% ee (Scheme 1). Asymmetric 74 epoxides were characterized by comparing with the literature value of ¹H-NMR and 75 enantiomeric excess was determined by chiral HPLC column and optical rotation in 76 chloroform.²⁴ 77

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[Scheme 1]

It was observed that during the ring opening of epoxides, the C-2 configuration remained same 79 while the C-3 configuration changed due to S_N 1-like mechanism therefore it gave the regio- and 80 stereoselective intramolecular Friedel-Crafts alkylation. The protons at C-2 and C-3 positions are 81 in *trans*-orientation which is confirmed by the coupling constant (J = 2.0 Hz) in ¹H-NMR 82 spectrum. ²⁴ The absolute configurations at C-2 and C-3 are confirmed as 2R and 3S respectively. 83 The stereoselectivity and high yields for 1-indanones under acidic condition (SnCl₄) might be 84 due to the variable oxidation state and availability of relatively low energy 5d-orbitals on tin. On 85 ligation with epoxide oxygen, the tetrahedron structure of SnCl₄ was converted to a trigonal 86 bipyramid/octahedron structure. This geometrical change enhanced the steric hindrance which 87 results in a faster epoxide ring opening from β -carbon due to considerable electron deficient 88 character at benzylic carbon. Therefore, the nucleophile attacked at β -carbon of carbonyl group. 89

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91 A proposed reaction mechanism is shown in Scheme 2 for the MOM ether deprotection and the sequel intramolecular Friedel-Crafts alkylation, where ligation of SnCl₄ with MOM oxygen 92 resulted in the removal of the methyl (methylene) oxonium group followed by its reaction with 93 Cl⁻ generated the MOMCl.²³ Same time, the epoxide oxygen ligation with SnCl₄ might change 94 the tetrahedron structure of SnCl₄ into trigonal bipyramid/octahedron structure. The geometry 95 changes enhanced the steric hindrance which results in faster epoxide ring opening from β -96 carbon due to considerable electron deficient character at benzylic position not on α -carbon due 97 to a 4-membered cyclobutanone (unstable intermediate). Therefore, the nucleophilic attack took 98 place at β -carbon of carbonyl which gave a resonance stabilized benzyl intermediate. Finally, a 99 base hydrolysis regenerated SnCl₄ catalyst which is used in the next catalytic-cycle. 100

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[Scheme 2]

In conclusion, we have illustrated an optimized reaction conditions for the rapid and efficient deprotection of the phenolic THP and MOM ethers and sequel intramolecular Friedel-Crafts alkylation reaction of chalcone epoxides. All reactions were completed within 2-3 min and gave excellent yield (90-98%) at 0 $^{\circ}$ C for both the THP and the MOM ethers and sequel cyclization reactions without affecting the other functional groups.

107

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111 Supplementary Material

- 112 Experimental procedures and the characterization data ¹H, ¹³C NMR spectra and chiral HPLC
- 113 chromatogram associated with this article are available.

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- General procedure for the deprotection of tetrahydropyranyl and methoxymethyl ethers of
 alcohols and phenols: SnCl₄ (10 moles %) was added to a stirred solution of THP/MOM

ethers (1 mmol) in CH₂Cl₂ (5 mL) at 0 °C. TLC monitoring, the reaction mixture was 158 poured into 10% aqueous Na₂CO₃ solution and extracted with CH₂Cl₂. The combined 159 organic layer was washed with brine solution, dried with anhyd. Na₂SO₄ and concentrated 160 161 in *vacuo* to afford the corresponding alcohol or phenol, which was purified by silica gel column chromatography with hexane-EtOAc eluent to obtain the products 1-19 in excellent 162 yield (90-98%). Characterization for example, (E)-1-(4-chlorophenyl)-3-(4-hydroxy 163 phenyl)prop-2-en-1-one(11): ¹H NMR (CDCl₃, 500 MHz) δ ppm7.87 (d, J = 8.5 Hz, 2H) 164 7.54 (d, J = 8.5 Hz, 1H), 7.06 (d, 9 Hz, 1H), 6.95 (d, J = 9 Hz, 2H), 6.40 (s, 1H) 5.29 (t, 7) 165 Hz,1H), 5.22 (d, J = 1.5 Hz,1H). ¹³C NMR (CDCl₃, 125 MHz) δ ppm 195.55, 161.83, 166 137.36, 131.82, 131.42, 129.79, 125.99, 123.01, 116.23, 76.32, 63.53. GC-MS(m/z): 258 167 [M⁺,C₁₅H₁₁FO₃]. 3-(4-bromophenyl)-2,5-dihydroxy-2,3-dihydroinden-1-one (13): ¹H NMR 168 $(CDCl_3, 500 \text{ MHz}) \delta ppm 7.86 \text{ (d, } J = 8.5 \text{ Hz}, 2H_1, 7.54-7.52 \text{ (m, 1H)}, 7.05 \text{ (t, 7 Hz, 1H)},$ 169 6.95 (d, J = 9 Hz, 2H), 6.42 (s, 1H), 5.29 (t, 7 Hz, 1H), 5.22 (d, J = 1.5 Hz, 1H). ¹³C NMR 170 (CDCl₃, 125 MHz) δ ppm 195.57, 161.85, 137.38, 131.84, 131.45, 129.81, 126.01, 123.04, 171 116.25, 75.40, 63.55. GC-MS (m/z): 318 [M^{+,}, C₁₅H₁₁BrO₃], 320 [M+2]. 172

173

174 Caption to illustrations

Table 1. Optimization conditions in deprotection of the THP and the MOM ethers and sequel
 cyclization of phenolic compounds with different catalysts

- **Table 2.** Solvent effects on yields in deprotection of the THP and the MOM ethers and sequelcyclization reaction
- 179 **Table 3.** Examples of the THP and MOM ethers deprotection and sequel cyclization reaction
- 180 Scheme 1. Synthesis of diastereoisomerically pure trans-3-(4-bromophenyl)-2-hydroxy-2,3-

- dihydroindan-1-one 181
- 182 Scheme 2. A propose mechanism for the deprotection of MOM ethers followed by cyclization 183 with SnCl₄
- Table 1. Optimization conditions in deprotection of the THP and the MOM ethers and sequel 184
- cyclization of phenolic compounds with different catalysts 185



^a Gave only cyclization.

204

^b Gave both THP and MOM ethers deprotection and sequel cyclization.

| 205 | ^C Other product as 3-(4-chlorophenyl)-2-chloro-2,3-dihydro indan-1-one |
|-----|---|
| 206 | (20%). |

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Table 2. Solvent effects on yields in deprotection of the THP and the MOM ethers and sequel

209 cyclization reaction











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- 217 Scheme 1. Synthesis of diastereoisomerically pure trans-3-(4-bromophenyl)-2-hydroxy-2,3-
- 218 dihydroindan-1-one.





Graphical Abstract

